

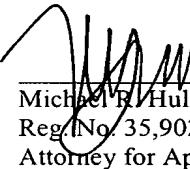
1752
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PATENT
30205/38082



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Geun Su Lee et al.)
Serial No.: 10/079,348)
Filed: February 20, 2002)
For: Photoresist Monomers, Polymers)
Thereof and Photoresist Compositions)
Containing the Same)
Group Art Unit: 1752)
Examiner: Rosemary E. Ashton)
)

I hereby certify that this paper and the
documents referred to as enclosed
therewith are being deposited with the
United States Postal Service as first class
mail, postage prepaid, on April 27, 2004,
in an envelope addressed to
Commissioner for Patents, P.O. Box
1450, Alexandria, Virginia 22313-1450


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AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

In response to the office action mailed on March 4, 2004, please amend
the above-identified patent application as follows.

Amendments to the claims and a complete listing of the claims begin
on page 2 of this paper.

Remarks begin on page 11 of this paper.